	Application No.	Applicant(s)	
Notice of Allowability	09/305,722 Examiner	BAO ET AL. Art Unit	<u>-</u>
	Examiner	Artollit	
	Anita K Alanko	1765	<del></del>
The MAILING DATE of this communication at All claims being allowable, PROSECUTION ON THE MERITS herewith (or previously mailed), a Notice of Allowance (PTOL-NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT of the Office or upon petition by the applicant. See 37 CFR 1.3	IS (OR REMAINS) CLOSED in 85) or other appropriate commin RIGHTS. This application is a	n this application. If not include unication will be mailed in due o	d course <b>THIS</b>
<ol> <li>This communication is responsive to 10/31/03.</li> <li>The allowed claim(s) is/are 1,3-5,7-9,11,12 and 19.</li> <li>The drawings filed on 11/30/00 are accepted by the Examulation Acknowledgment is made of a claim for foreign priority a) ☐ All b) ☐ Some* c) ☐ None of the:</li> </ol>		or (f).	
1. ☐ Certified copies of the priority documents ha	ave heen received		
Certified copies of the priority documents have		n No	
Copies of the certified copies of the priority	- · ·		on from the
International Bureau (PCT Rule 17.2(a)).		a in this hational stage applicati	on nom me
* Certified copies not received:	•		
<ul> <li>5. Acknowledgment is made of a claim for domestic priority reference was included in the first sentence of the specion (a) The translation of the foreign language provisions</li> <li>6. Acknowledgment is made of a claim for domestic priority in the first sentence of the specification or in an Applicat</li> </ul>	fication or in an Application Da al application has been receive y under 35 U.S.C. §§ 120 and/o	ta Sheet. 37 CFR 1.78. d.	
Applicant has THREE MONTHS FROM THE "MAILING DATE" below. Failure to timely comply will result in ABANDONMENT	of this application. THIS THR	EE-MONTH PERIOD IS NOT E	EXTENDABLE.
<ol> <li>A SUBSTITUTE OATH OR DECLARATION must be sull INFORMAL PATENT APPLICATION (PTO-152) which g</li> </ol>	gives reason(s) why the oath or	AMINER'S AMENDMENT or NO declaration is deficient.	OTICE OF
<ol> <li>CORRECTED DRAWINGS (as "replacement sheets") n         <ul> <li>(a) ☐ including changes required by the Notice of Draftsp</li> <li>1) ☐ hereto or 2) ☐ to Paper No</li> <li>(b) ☐ including changes required by the proposed drawing</li> </ul> </li> </ol>	erson's Patent Drawing Reviev		aminar
(c) ☐ including changes required by the attached Examin			
Identifying indicia such as the application number (see 37 CFF each sheet. Replacement sheet(s) should be labeled as such i	R 1.84(c)) should be written on the margin according to 37 CF	e drawings in the front (not the t R 1.121(d).	pack) of
<ol> <li>DEPOSIT OF and/or INFORMATION about the delattached Examiner's comment regarding REQUIREMENT FOR</li> </ol>	posit of BIOLOGICAL MATE R THE DEPOSIT OF BIOLOGIC	ERIAL must be submitted. No CAL MATERIAL.	ote the
Attachment(s)			
1☐ Notice of References Cited (PTO-892)	5☐ Notice of Info	rmal Patent Application (PTO-1	152)
2☐ Notice of Draftperson's Patent Drawing Review (PTO-948)	<b>—</b>	nmary (PTO-413), Paper No	······································
3 Information Disclosure Statements (PTO-1449 or PTO/SB/ Paper No	<sup>/08</sup> ), 7☐ Examiner's A	mendment/Comment	
Faper No 4☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material	<u></u>	tatement of Reasons for Allowa Aruta K. Hlcr Anita K Alanko Primary Examiner Art Unit: 1765	

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CLMPTO

12/17/03

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1.(Previously Amended) A method for forming at making an organic transistor on a substrate comprising the steps of:

providing a substrate including a metal surface layer;

providing a rotatable stamp having relief geometries on its surface to define a stamping surface;

applying a self-assembled monolayer ink to the surface of the rotatable stamp to define an inked stamping surface;

rotating the rotatable stamp on the metal surface layer as the layer is placed in contact with the stamp to impress on the layer an inked pattern as defined by the inked stamping surface; and

patterning the layer by etching material from the layer wherein the inked stamping surface guides the etching in a geometry to define the patterned layer useful in fabricating an electronic device;

removing the inked pattern from the layer; and

applying an organic semiconductor layer overlying the etched metal layer.

Claim 2 is canceled.

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- 3.(Original) The method of claim 1, in which the step of providing the rotatable stamp comprises:
  - (a) casting a liquid onto a surface having relief geometries thereon;
  - (b) solidifying the liquid to define a solid film; and
- (c) rolling a member over the solid film so that the solid film is lifted from the surface and bonds to the member.
- 4.(Original) The method of claim 3, in which the liquid comprises an elastomeric material, the step of solidifying the liquid comprises curing the elastomeric material to form an elastomeric film.
- 5.(Original) The method of claim 4, further comprising a step of exposing the cured elastomeric film to oxygen plasma before the member is rolled over the film.
  Claim 6 is canceled.
  - 7.(Currently Amended) The method of claim [6] 1 in which the metal surface layer [at least one coating layer] includes a thin layer of gold or silver.
  - 8.(Previously Amended) The method of claim 1 in which the step of patterning the metal layer comprises etching material from the substrate applying an etchant selected from the group consisting of aqueous ferrocyanide, K<sub>4</sub>Fe(CN)<sub>6</sub>, K<sub>3</sub>Fe(CN)<sub>6</sub>, Na<sub>2</sub>S<sub>2</sub>O<sub>3</sub>, and KOH in H<sub>2</sub>O.

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9.(Original) The method of claim 1, in which the step of rotating the stamp provides an exposed region on the metal layer where substantially no ink is present and a protected region on the layer where ink substantially covers protected region.

Claim 10 is canceled.

11. The method of claim [10] 1, in which the metal surface layer has an applied adhesive layer selected from the group consisting of Ti and Cr.

12.(Previously Amended) The method of claim 1 in which the inked pattern is removed by ultraviolet light, heat, or wet chemical cleaning.

Claims 13-18 are canceled.

19.(Previously Amended) The method of claim 3 wherein the member comprises a cylinder with a glass surface.

Claims 20-22 are canceled.